

## PRODUCT/PROCESS CHANGE NOTIFICATION

PCN MMS-MMY/09/4680 Notification Date 06/17/2009

## M24512, 512Kbit Serial I2C Bus EEPROM Redesign and Upgrade to the CMOSF8H Process Technology

#### Table 1. Change Implementation Schedule

Forecasted implementation date for change	10-Jun-2009
Forecasted availability date of samples for customer	10-Jun-2009
Forecasted date for <b>STMicroelectronics</b> change Qualification Plan results availability	10-Jun-2009
Estimated date of changed product first shipment	16-Sep-2009

### Table 2. Change Identification

Product Identification (Product Family/Commercial Product)	M24512 products family	
Type of change	Waferfab technology change	
Reason for change	Line up to state of art of design	
Description of the change	Redesign and Upgrade to the new CMOSF8H Process Technology	
Product Line(s) and/or Part Number(s)	See attached	
Description of the Qualification Plan	See attached	
Change Product Identification	Process Techno identifier is "K" for CMOSF8H upgraded version	
Manufacturing Location(s)		

#### Table 3. List of Attachments

Customer Part numbers list	
Qualification Plan results	

Customer Acknowledgement of Receipt	PCN MMS-MMY/09/4680
Please sign and return to STMicroelectronics Sales Office	Notification Date 06/17/2009
Qualification Plan Denied	Name:
Qualification Plan Approved	Title:
	Company:
Change Denied	Date:
Change Approved	Signature:
Remark	
· ·····	

Name	Function	
Leduc, Hubert	Division Marketing Manager	
Rodrigues, Benoit	Division Product Manager	
Malbranche, Jean-Luc	Division Q.A. Manager	

## **DOCUMENT APPROVAL**



## What is the change?

The **M24512**, 512Kbit Serial I<sup>2</sup>C Bus EEPROM product family, currently produced using the CMOSF8L Process Technology in the ST Rousset (France) 8 inch wafer diffusion plant has been **redesigned** and will be **upgraded** to the **CMOSF8H** Process Technology in the same wafer diffusion plant.

The same part number will support operation with bus frequency at 1 MHz, 400kHz or 100 kHz (see datasheet rev.14 dated June 2009) removing the need for M24512-H ordering when 1 MHz operation is requested (see appendix B).

Following parameters are updated:

- tCLQV = 100ns (AC characteristics at 1 MHz, 400kHz or 100 kHz)
- tNS = 80ns (AC characteristics at 1 MHz, 400kHz or 100 kHz)
- ESD HBM passes 3000V

For other parameters, upgraded version is functionally backward compatible to previous version, as per datasheet rev.13 dated Jan. 2009.

### Why?

The strategy of STMicroelectronics Memory Division is to support our customers on a long-term basis. In line with this commitment, the qualification of the M24512 in the new CMOSF8H Process Technology will increase the production capacity throughput and consequently improve the service to our customers.

Also, the new die is fitting the MLP 2x3 package (M24512-RMB6TG).

## When?

The production of the upgraded M24512 with the new CMOSF8H will ramp up from June 2009 and shipments can start from September 2009 onward (or earlier upon customer approval).

#### How will the change be qualified?

The new version of the M24512 has been qualified using the standard ST Microelectronics Corporate Procedures for Quality and Reliability.

The CMOSF8H is already qualified on the M95512 product family.

The Qualification Report QREE0806 is available and included inside this document.

## What is the impact of the change?

- Form: marking change (see Device marking paragraph)
- Fit: no change
- Function: change on AC performances and ESD HBM (Datasheet updated)

## How can the change be seen?

## - BOX LABEL MARKING

On the BOX LABEL MARKING, the difference is visible inside the **Finished Good Part Number**: the **Process Technology** identifier is "**K**" for the **upgraded version**, this identifier being "A" for the current version.

→ Example for M24512-WMN6TP (2.5V to 5.5V Vcc range, SO8N – ECOPACK<sup>®</sup> 2\* compliant package)

\* ECOPACK<sup>®</sup> 2: New grade introduced to identify commonly called "Halogen-Free" products on the market. This grade is also RoHS compliant. (ECOPACK<sup>®</sup> is a registered trademark of STMicroelectronics)

Commercial Part Number (CP)			
TYPE:	M24512-WMN6TP		
	Finished Good Part Number (FG) M24512-WMN6TP/K <u>x x x</u>		
	Process Technology Mask revision   "K" for the new version in CMOSF8H and/or   "A" for the current version in CMOSF8L Wafer diffusion plant   Assembly and Test & Finishing (*) plants		
Trace Code	(*): This digit is present for Test only when Test plant differs from Assembly plant. PPYWWLLL VG TF		

## How can the change be seen?

## - DEVICE MARKING

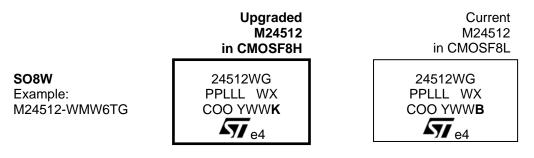
On the DEVICE MARKING of the **SO8N** package, the difference is visible inside the trace code (PYWWT) where the last digit "T" for **Process Technology** identifier is "**K**" for the **upgraded version** in **CMOSF8H**, the identifier being "B" for the current version in CMOSF8L.



For **TSSOP8**, the difference is visible inside the product name: **upgraded version** in **CMOSF8H** is ending by "**K**", the current version was ending by "P".



For **SO8W**, the difference is visible inside the trace code: **upgraded version** in **CMOSF8H** is ending by "**K**", the current version was ending by "B".



P or PP= Assembly plant / country
LLL= chronological sequence
WX= wafer fab
COO= Country Of origin
Y = Last digit of the Year of Assembly
WW = Assembly Week code
T = Process Technology code/ Wafer Fab ID

## Appendix A- Product Change Information

Product family / Commercial products:	M24512 products family	
Customer(s):	All	
Type of change:	Wafer fab Process Technology change	
Reason for the change:	Line up to state of art of design.	
Description of the change:	Redesign and Upgrade to the new CMOSF8H Process Technology.	
Forecast date of the change:	Week 24 / 2009	
Forecast date of <u>Qualification samples</u> availability for customer(s):	Available	
Forecast date for the internal STMicroelectronics change, <u>Qualification Report</u> availability:	QREE0806 is available and included inside this document	
Marking to identify the changed product:	Process and fab ID see marking above	
Description of the qualification program:	Standard ST Microelectronics Corporate Procedures for Quality and Reliability	
Product Line(s) and/or Part Number(s):	See Appendix B	
Manufacturing location:	Rousset 8 inch wafer fab	
Estimated date of first shipment:	Week 38 / 2009	

## Appendix B: Concerned Commercial Part Numbers:

M24512-WMN6P	]	
M24512-WMN6TP		
M24512-WDW6TP		
M24512-WMW6G		
M24512-WMW6TG		
M24512-RDW6TP		
M24512-RMN6P		
M24512-RMN6TP		
M24512-HRDW6TP	replaced by	M24512-RDW6TP
M24512-HRMN6P	replaced by	M24512-RMN6P
M24512-HRMN6TP	replaced by	M24512-RMN6TP

## **Appendix C: Qualification Report:**



#### Table 1. Product information

General information		
Commercial product	M24512-RMN6P M24512-RMN6TP M24512-WMN6P M24512-WMN6TP M24512-RDW6TP M24512-WDW6TP	
Product description	512 Kbit serial PC bus EEPROM with three Chip Enable lines	
Product group	MMS	
Product division	MMY - Memory	
Silicon process technology	CMOSF8H	
Wafer fabrication location	RS8F - ST Rousset 8", France	
Electrical Wafer Sort test plant location ST Rousset, France		

Table 2. Package description

Package description	Assembly plant location	Final test plant location	
SO8N	ST Shenzhen, China	ST Shenzhen, China	
3001	Amkor P1, Philippines	Amkor P3, Philippines	
TSSOP8	ST Shenzhen, China	ST Shenzhen, China	
1330F0	Amkor P1, Philippines	Amkor P3, Philippines	

Reliability / Qualification assessment: PASS

June 2009

Rev 1

1/11 www.st.com Reliability evaluation overview

QREE0806

## 1 Reliability evaluation overview

### 1.1 Objectives

This qualification report summarizes the results of the reliability trials that were performed to qualify the new M24512-W, M24512-R and M24512-DR devices using the CMOSF8H silicon process technology in the ST Rousset 8" diffusion fab.

The voltage and temperature ranges covered by this document are:

2.5 to 5.5 V at -40 to 85 °C for M24512-W devices

1.8 to 5.5 V at -40 to 85 °C for M24512-R and M24512-DR devices

The CMOSF8H is a new advanced silicon process technology in the ST Rousset 8" fab, with Double Poly and Double Metal process. This document serves for the qualification of the named product and the named silicon process technology in the named diffusion fab.

#### 1.2 Conclusion

The new M24512-W, M24512-R and M24512-DR devices using the CMOSF8H silicon process technology in the ST Rousset 8" diffusion fab have passed the reliability requirements and all products described in *Table 1* are qualified.

Refer to Section 3: Reliability test results for details on the reliability test results.

2/11



#### QREE0806

### 2 Device characteristics

#### Device description

The M24512-W, M24512-R, M24512-DR devices are I<sup>2</sup>C-compatible electrically erasable programmable memories (EEPROM). They are organized as 64 Kb  $\times$  8 bits.

I<sup>2</sup>C uses a two-wire serial interface, comprising a bidirectional data line and a clock line. The devices carry a built-in 4-bit Device Type Identifier code (1010) in accordance with the I<sup>2</sup>C bus definition.

The device behaves as a slave in the I<sup>2</sup>C protocol, with all memory operations synchronized by the serial clock. Read and Write operations are initiated by a Start condition, generated by the bus master. The Start condition is followed by a device select code and Read/Write bit (RW), terminated by an acknowledge bit.

When writing data to the memory, the device inserts an acknowledge bit during the 9th bit time, following the bus master's 8-bit transmission. When data is read by the bus master, the bus master acknowledges the receipt of the data byte in the same way. Data transfers are terminated by a Stop condition after an Ack for Write, and after a NoAck for Read.

Refer to the product datasheet for more details.



Rev 1

## 3 Reliability test results

This section contains a general description of the reliability evaluation strategy.

The named products are qualified using the standard STMicroelectronics corporate procedures for quality and reliability.

The product vehicle used for the die qualification is presented in Table 3.

Table 3. Product vehicles used for die qualification

Product	Silicon process technology	Wafer fabrication location	Package description	Assembly plant location
M24512 <sup>(1)</sup>	CMOSF8H	ST Rousset 8"	CDIP8	Engi assy <sup>(2)</sup>
M95512	CMOSF8H	ST Rousset 8"	CDIP8	Engi assy (2)

 Die-oriented reilability tests majnly based on M95512 product (same silicon process technology, same design core between 512 Kbit I<sup>2</sup>C and 512 Kbit SPI / Metal mask option for bus control).

2. CDIP8 is a ceramic package used only for die-oriented reliability trials.

The package qualifications were mainly obtained by similarity. The product vehicle and silicon process technologies used for package qualification are presented in *Table 4*.

Table 4. Product vehicles used for package qualification

Product	Silicon process technology	Wafer fabrication location	Package description	Assembly plant location
			SO8N	ST Shenzhen & Amkor P1
M95512 <sup>(1)</sup>	CMOSF8H	ST Rousset 8"	TSSOP8	ST Shenzhen & Amkor P1
			UFDFPN8 (MLP8) 2 x 3 mm	Amkor P3
M24512	CMOSF8H	ST Rousset 8"	SO8W	Amkor P1
M24012	GWICSFOR			Stats ChipPac

 Package qualification results of M95512 are applicable (same silicon process technology, same memory array between 512 Kbit I<sup>2</sup>C and 512 Kbit SPI / Metal mask option for bus control).

#### 3.1 Reliability test plan and result summary

The reliability test plan and the result summary are presented as follows:

- In Table 5 for die-oriented tests
- In Table 6 for SO8N ST Shenzhen & Amkor P1 package-oriented tests
- In Table 7 for TSSOP8 ST Shenzhen & Amkor P1 package-oriented tests
- Reliability tests on all other packages are planned, but results are not yet available.

4/11



QREE0806

Reliability test results

	Test short description										
		Conditions				Re	size				
Test	Method		Sample No. size / of Duration lots lots		M95512			M24512 (2)			
						Lot 1	Lot 2	Lot 3	Lot 4		
	High temperature operating life after endurance										
EDR	AEC-Q100-005	1 Million E/W cycles at 25 °C then: HTOL 150 °C, 6 V	80	1	1008 hrs	0/80	0/80	0/80	-		
L'DIX .	Data retention af	ter endurance									
	AEC-Q100-005	1Million E/W cycles at 25 °C then: HTSL at 150 °C	80	1	1008 hrs	0/80	0/80	0/80	-		
LTOL	Low temperature	operating life									
	JESD22-A108	-40 °C, 6 V	80	1	1008 hrs	0/80	0/80	0/80	-		
	High temperatur	e storage life									
HTSL	AEC-Q100-005 JESD22-A103	Retention bake at 200 °C	80	1	1008 hrs	0/80	0/80	0/80	-		
	Program/erase e	ndurance cycling + bake									
WEB	Internal spec.	1 Million E/W cycles at 25 °C then: Retention bake at 200 °C / 48 hours	80	1	1 Million cycles / 48 hrs	0/80 <sup>(3)</sup>	0/80 <sup>(3)</sup>	0/80 <sup>(3)</sup>	-		
ESD .	Electrostatic disc	harge (human body model)									
нвм	AEC-Q100-002 JESD22-A114	C = 100 pF, R= 1500 Ω	27	1	N/A	Pass > 3000 V	Pass > 3000 V	Pass > 3000 V	Pass > 3000 V		
ESD .	Electrostatic disc	harge (machine model)									
MM	AEC-Q100-003 JESD22-A115	C = 200 pF, R = 0 Ω	6	1	N/A	Pass > 300 V	Pass > 300 V	Pass > 300 V	Pass > 300 V		
	Latch-up (curren	t injection and overvoltage str	ess)								
LU	AEC-Q100-004 JESD78A	At maximum operating temperature (150 °C)	6	1	N/A	Class II Level A	Class II Level A	Class II Level A	Class II Level A		

#### Table 5. Die-oriented reliability test plan and result summary (CDIP8 / Engineering package)<sup>(1)</sup>

1. See Table 8: List of terms for a definition of abbreviations.

 Die-oriented reliability tests mainly based on M95512 product (same silicon process technology, same design core between 512 Kbit I<sup>2</sup>C and 512 Kbit SPI / Metal mask option for bus control).

3. First rejects after 3 million cycles + bake.

57

Rev 1

#### Reliability test results

QREE0806

	P1)*7									
	Test short description									
Test		Conditions	Sample No. size / of	No		Results fail / sample size			e size	
	Method			Duration	M	95512 <sup>(2)</sup>		M24512		
			1015	lots		Lot1	Lot2	Lot3	Lot 4	
	Preconditioning: moisture sensitivity level 1									
PC	JESD22-A113 J-STD-020D	MSL1, peak temperature at 260 °C, 3 IReflow	345	1	N/A	0/400	0/400	0/400	-	
тир	Temperature hu	imidity bias								
THB (3)	AEC-Q100- JESD22-A101	85 °C, 85% RH, bias 5.5 V	80	1	1008 hrs	0/80	0/80	0/80	-	
	Temperature cycling									
TC (3)	AEC-Q100- JESD22-A104	-65 °C / +150 °C	80	1	1000 cycles	0/80	0/80	0/80	-	
TMSK	Thermal shocks									
(3)	JESD22-A106	–55 °C / +125 °C	25	1	200 shocks	0/80	0/80	0/80	-	
	Autoclave (pres	sure pot)								
AC (3)	AEC-Q100- JESD22-A102	121 °C, 100% RH at 2 ATM	80	1	168 hrs	0/80	0/80	0/80	-	
HTSL	High temperatu	re storage life								
(3)	AEC-Q100- JESD22-A103	Retention bake at 150 °C	80	1	1008 hrs	0/80	0/80	0/80	-	
	Early life failure	rate								
ELFR	AEC-Q100- 008	HTOL 150 °C, 6 V	800	1	48 hrs	0/800	0/800	0/800	-	
ESD	Electrostatic dis	scharge (charge device mode	I)		•	•				
CDM	AEC-Q100- JESD22-C101	Field induced charging method	18	1	N/A	Pass >1500 V	-	-	Pass >1500 V	

## Table 6. Package-oriented reliability test plan and result summary (SO8N / Shenzhen & Amkor P1)<sup>(1)</sup>

1. See Table 8: List of terms for a definition of abbreviations.

 Package qualification results of M95512 are applicable (same silicon process technology, same memory array between 512 Kbit I<sup>2</sup>C and 512 Kbit SPI / Metal mask option for bus control).

3. THB-, TC-, TMSK-, AC- and HTSL- dedicated parts are first subject to preconditioning flow.

6/11



#### QREE0806

Reliability test results

		Test short description									
Test	Method	Conditions	size /	of	Duration	Results fail / sample siz			e size		
Test						M95512 <sup>(2)</sup>			M24512		
			lots	lots		Lot1	Lot2	Lot3	Lot4		
	Preconditioning: moisture sensitivity level 1										
PC	JESD22-A113 J-STD-020D	MSL1, peak temperature at 260 °C, 3 IReflow	345	1	N/A	0/400	0/400	0/400	-		
тнв	Temperature hu	midity bias									
(3)	AEC-Q100- JESD22-A101	85 °C, 85% RH, bias 5.5 V	80	1	1008 hrs	0/80	0/80	0/80	-		
	Temperature cycling										
TC <sup>(3)</sup>	AEC-Q100- JESD22-A104	-65 °C / +150 °C	80	1	1000 cycles	0/80	0/80	0/80	-		
TMSK	Thermal shocks										
(3)	JESD22-A106	–55 °C / +125 °C	25	1	200 shocks	0/80	0/80	0/80	-		
	Autoclave (pres	sure pot)									
AC (3)	AEC-Q100- JESD22-A102	121 °C, 100% RH at 2 ATM	80	1	168 hrs	0/80	0/80	0/80	-		
HTSL	High temperatu	re storage life									
(3)	AEC-Q100- JESD22-A103	Retention bake at 150 °C	80	1	1008 hrs	0/80	0/80	0/80	-		
	Early life failure	Early life failure rate									
ELFR	AEC-Q100- 008	HTOL 150 °C, 6 V	800	1	48 hrs	0/800	0/800	0/800	-		
ESD	Electrostatic dis	charge (charge device mod	el)			-					
CDM	AEC-Q100- JESD22-C101	Field induced charging method	18	1	N/A	Pass >1500 V	-	-	Pass >1500 V		

# Table 7. Package-oriented reliability test plan and result summary (TSSOP8 / Shenzhen & Amkor P1)<sup>(1)</sup>

1. See Table 8: List of terms for a definition of abbreviations.

 Package gualification results of M95512 are applicable (same silicon process technology, same memory array between 512 Kbit I<sup>+</sup>C and 512 Kbit SPI / Metal mask option for bus control).

3. THB-, TC-, TMSK-, AC- and HTSL- dedicated parts are first subject to preconditioning flow.



Rev 1

Applicable and reference documents

#### QREE0806

## 4 Applicable and reference documents

- AEC-Q100: Stress test qualification for integrated circuits
- SOP 2.6.10: General product qualification procedure
- SOP 2.6.11: Program management fro product qualification
- SOP 2.6.12: Design criteria for product qualification
- SOP 2.6.14: Reliability requirements for product qualification
- SOP 2.6.19: Process maturity level
- SOP 2.6.2: Process qualification and transfer management
- SOP 2.6.20: New process / New product qualification
- SOP 2.6.7: Product maturity level
- SOP 2.6.9: Package and process maturity management in Back End
- SOP 2.7.5: Automotive products definition and status
- JESD22-A101: Steady state temperature humidity bias life test
- JESD22-A102: Accelerated moisture resistance unbiased autoclave
- JESD22-A103: High temperature storage life
- JESD22-A104: Temperature cycling
- JESD22-A106: Thermal shock
- JESD22-A108: Temperature, bias, and operating life
- JESD22-A113: Preconditioning of nonhermetic surface mount devices prior to reliability testing
- JESD22-A114: electrostatic discharge (ESD) sensitivity testing human body model (HBM)
- JESD22-A115: Electrostatic discharge (ESD) sensitivity testing machine model (MM)
- JESD78A: IC Latch-up test
- J-STD-020D: Moisture/reflow sensitivity classification for nonhermetic solid state surface mount devices

8/11



#### QREE0806

Glossary

## 5 Glossary

Terms	Description
EDR	NVM endurance, data retention and operational life
HTOL	High temperature operating life
LTOL	Low temperature operating life
нтв	High temperature bake
WEB	Program/Erase endurance cycling + bake
ESD HBM	Electrostatic discharge (human body model)
SD MM	Electrostatic discharge (machine model)
.U	Latch-up
°C	Preconditioning (solder simulation)
нв	Temperature humidity bias
ic .	Temperature cycling
rmsk	Thermal shocks
AC	Autoclave (pressure pot)
ITSL	High temperature storage life
LFR	Early life failure rate
SD CDM	Electrostatic discharge (charge device model)



Rev 1

Revision history

QREE0806

## 6 Revision history

Table 9. Document revision history

Date	Revision	Changes
03-Jun-2009	1	Initial release.

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1	u	П	1



#### QREE0806

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Rev 1

Document Re	evision	History	
Date	Description of the Revision		
June 03, 2009	1.00	First draft creation	

Source Documents & Reference Documents						
Source document Title		Rev.:	Date:			

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